

Attn: DO/US

IN THE UNITED STATES DESIGNATED OFFICE (DO/US)

Applicant(s): Pascal Doppelt
International Appl. No.: PCT/FR03/02820
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Title: FLUORINE-FREE METALLIC COMPLEXES FOR GAS-PHASE CHEMICAL METAL DEPOSITION

Docket No.: 033339/290594
Customer No.: 00826

Mail Stop PCT
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

**PRELIMINARY AMENDMENT
37 CFR § 1.115**

Sir:

Please enter this Preliminary Amendment before calculating the claim fee and amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims beginning on page 3 of this paper.

Remarks begin on page 7 of this paper.